What is claimed is:

- A method for manufacturing a mid-plane, comprising the steps of:
 providing a multi-layer board having a connection assembly;
 providing a layer with a channel formed therein to define a perimeter of a connector area;
 - bonding the layer to the multi-layer board such that the connector area overlaps the part of the connection assembly of the multi-layer board; and removing at least a portion of the connector area in the layer to expose the connection
- 2. The method of claim 1, wherein the layer is bonded to the multi-layer board so as to form a space between the layer and the connection assembly of the multi-layer board.

assembly of the multi-layer board.

- 3. The method of claim 1, wherein the layer is bonded to a conductive layer to form a metallic foil.
- 4. The method of claim 3, wherein the metallic foil is a single sided copper clad laminate whereby the conductive layer is formed of copper and the layer is applied to only one side of the conductive layer of copper.
- 5. The method of claim 1, wherein the step of removing at least a portion of the connector area is defined further as removing the connector area by depth controlled routing along the channel.
- 6. The method of claim 1, wherein the multi-layer board is coated with a surface finish prior to the step of bonding the layer to the multi-layer board.
- 7. A method for manufacturing a mid-plane, comprising the steps of: providing two multi-layer boards with each having a connection assembly; providing first and second layers with each having a channel formed therein to define a perimeter of a connector area;
 - bonding the first layer to one of the multi-layer boards and the second layer to the other one of the multi-layer boards such that the connector areas overlap the respective connection assemblys of the multi-layer boards;

- bonding the multi-layer boards together to form a rigid multilayer wherein the first layer is positioned on one side of the rigid multilayer and the second layer is positioned on an opposite side of the rigid multilayer; and
- removing at least a portion of the connector areas in the first and second layers to expose the respective connection assemblys.
- 8. The method of claim 7, wherein each of the layers are bonded to the multi-layer boards so as to form a space between the layer and the connection assembly of the multi-layer board.
- 9. The method of claim 7, wherein the layer is bonded to a conductive layer to form a metallic foil.
- 10. The method of claim 9, wherein the metallic foil is a single sided copper clad laminate whereby the conductive layer is formed of copper and the layer is applied to only one side of the layer of copper.
- 11. The method of claim 7, wherein the step of removing at least a portion of the connector areas is defined further as removing the connector areas by depth controlled routing along the channels.
- 12. The method of claim 7, wherein the multi-layer boards are coated with a surface finish prior to the step of bonding the layer to the multi-layer board.
- 13. A rigid multilayer, comprising:
 - a multi-layer board having a connection assembly;
 - a layer having a channel formed therein to define a perimeter of a connector area, the layer bonded to the multi-layer board such that the connector area overlaps the
 - connection assembly of the multi-layer board.
- 14. The rigid multilayer of claim 13, wherein the layer has a first side in which the channel is formed and wherein the first side of the layer faces the multi-layer board.
- 15. The rigid multilayer of claim 13, wherein the connector area of the layer is spaced a distance from the multi-layer board.

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16. The rigid multilayer of claim 13, further comprising a conductive layer extending over the layer such that the layer is positioned between the conductive layer and the multi-layer board.